

# International IOR Rectifier

## RADIATION HARDENED POWER MOSFET THRU-HOLE (T0-254AA)

## IRHM7230 200V, N-CHANNEL

### RAD Hard™ HEXFET® TECHNOLOGY

### Product Summary

Part Number	Radiation Level	RDS(on)	ID
IRHM7230	100K Rads (Si)	0.40Ω	9.0A
IRHM3230	300K Rads (Si)	0.40Ω	9.0A
IRHM4230	600K Rads (Si)	0.40Ω	9.0A
IRHM8230	1000K Rads (Si)	0.40Ω	9.0A



International Rectifier's RADHard HEXFET® technology provides high performance power MOSFETs for space applications. This technology has over a decade of proven performance and reliability in satellite applications. These devices have been characterized for both Total Dose and Single Event Effects (SEE). The combination of low Rds(on) and low gate charge reduces the power losses in switching applications such as DC to DC converters and motor control. These devices retain all of the well established advantages of MOSFETs such as voltage control, fast switching, ease of paralleling and temperature stability of electrical parameters.

### Features:

- Single Event Effect (SEE) Hardened
- Low RDS(on)
- Low Total Gate Charge
- Proton Tolerant
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed
- Ceramic Package
- Light Weight

### Absolute Maximum Ratings

### Pre-Irradiation

	Parameter		Units
ID @ VGS = 12V, TC = 25°C	Continuous Drain Current	9.0	A
ID @ VGS = 12V, TC = 100°C	Continuous Drain Current	6.0	
IDM	Pulsed Drain Current ①	36	
PD @ TC = 25°C	Max. Power Dissipation	75	W
	Linear Derating Factor	0.60	W/°C
VGS	Gate-to-Source Voltage	±20	V
EAS	Single Pulse Avalanche Energy ②	330	mJ
IAR	Avalanche Current ①	9.0	A
EAR	Repetitive Avalanche Energy ①	7.5	mJ
dv/dt	Peak Diode Recovery dv/dt ③	5.0	V/ns
TJ	Operating Junction	-55 to 150	°C
TSTG	Storage Temperature Range		
	Lead Temperature	300 ( 0.063 in.(1.6mm) from case for 10s)	
	Weight	9.3 (Typical )	g



**Electrical Characteristics @ Tj = 25°C (Unless Otherwise Specified)**

	Parameter	Min	Typ	Max	Units	Test Conditions
BVDSS	Drain-to-Source Breakdown Voltage	200	—	—	V	VGS = 0V, ID = 1.0mA
$\Delta BV_{DSS}/\Delta T_J$	Temperature Coefficient of Breakdown Voltage	—	0.27	—	V/°C	Reference to 25°C, ID = 1.0mA
RDS(on)	Static Drain-to-Source On-State Resistance	—	—	0.40	Ω	VGS = 12V, ID = 6.0A ④
		—	—	0.49		
VGS(th)	Gate Threshold Voltage	2.0	—	4.0	V	VDS = VGS, ID = 1.0mA
gfs	Forward Transconductance	3.0	—	—	S (Ω)	VDS > 15V, IDS = 6.0A ④
IDSS	Zero Gate Voltage Drain Current	—	—	25	μA	VDS = 160V, VGS = 0V
		—	—	250		
IGSS	Gate-to-Source Leakage Forward	—	—	100	nA	VGS = 20V
IGSS	Gate-to-Source Leakage Reverse	—	—	-100		VGS = -20V
Qg	Total Gate Charge	—	—	50	nC	VGS = 12V, ID = 9.0A VDS = 100V
Qgs	Gate-to-Source Charge	—	—	10		
Qgd	Gate-to-Drain ('Miller') Charge	—	—	20		
td(on)	Turn-On Delay Time	—	—	35		
tr	Rise Time	—	—	80	ns	VDD = 100V, ID = 9.0A VGS = 12V, RG = 7.5Ω
td(off)	Turn-Off Delay Time	—	—	60		
tf	Fall Time	—	—	46		
LS + LD package) Drain	Total Inductance	—	6.8	—	nH	Measured from Drain Lead (6mm/ 0.25in. from package) to source lead (6mm/0.25in from with Source wires bonded from Source Pin to Pad
Ciss	Input Capacitance	—	1100	—	pF	VGS = 0V, VDS = 25V f = 1.0MHz
Coss	Output Capacitance	—	250	—		
Crss	Reverse Transfer Capacitance	—	65	—		

**Source-Drain Diode Ratings and Characteristics**

	Parameter	Min	Typ	Max	Units	Test Conditions
IS	Continuous Source Current (Body Diode)	—	—	9.0	A	Tj = 25°C, IS = 9.0A, VGS = 0V ④
ISM	Pulse Source Current (Body Diode) ①	—	—	36		
VSD	Diode Forward Voltage	—	—	1.6	V	Tj = 25°C, IF = 9.0A, di/dt ≤ 100A/μs VDD ≤ 50V ④
trr	Reverse Recovery Time	—	—	460	nS	
QRR	Reverse Recovery Charge	—	—	5.0	μC	
ton	Forward Turn-On Time	Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by LS + LD.				

**Thermal Resistance**

	Parameter	Min	Typ	Max	Units	Test Conditions
RthJC	Junction-to-Case	—	—	1.67	°C/W	Typical socket mount
RthJA	Junction-to-Ambient	—	—	48		
RthCS	Case-to-Sink	—	0.21	—		

Note: Corresponding Spice and Saber models are available on the G&S Website.

For footnotes refer to the last page

# Radiation Characteristics

# IRHM7230

International Rectifier Radiation Hardened MOSFETs are tested to verify their radiation hardness capability. The hardness assurance program at International Rectifier is comprised of two radiation environments. Every manufacturing lot is tested for total ionizing dose (per notes 5 and 6) using the TO-3 package. Both pre- and post-irradiation performance are tested and specified using the same drive circuitry and test conditions in order to provide a direct comparison.

**Table 1. Electrical Characteristics @ Tj = 25°C, Post Total Dose Irradiation ⑤⑥**

Parameter	100 KRads(Si) <sup>1</sup>	300 - 1000K Rads (Si) <sup>2</sup>		Units	Test Conditions		
		Min	Max			Min	Max
BV <sub>DSS</sub>	Drain-to-Source Breakdown Voltage	200	—	200	—	V	V <sub>GS</sub> = 0V, I <sub>D</sub> = 1.0mA
V <sub>GS(th)</sub>	Gate Threshold Voltage	2.0	4.0	1.25	4.5		V <sub>GS</sub> = V <sub>DS</sub> , I <sub>D</sub> = 1.0mA
I <sub>GSS</sub>	Gate-to-Source Leakage Forward	—	100	—	100	nA	V <sub>GS</sub> = 20V
I <sub>GSS</sub>	Gate-to-Source Leakage Reverse	—	-100	—	-100		V <sub>GS</sub> = -20 V
I <sub>DSS</sub>	Zero Gate Voltage Drain Current	—	25	—	25	μA	V <sub>DS</sub> =160V, V <sub>GS</sub> =0V
R <sub>DS(on)</sub>	Static Drain-to-Source ④ On-State Resistance (TO-3)	—	0.40	—	0.53	Ω	V <sub>GS</sub> = 12V, I <sub>D</sub> =6.0A
R <sub>DS(on)</sub>	Static Drain-to-Source ④ On-State Resistance (TO-254AA)	—	0.40	—	0.53	Ω	V <sub>GS</sub> = 12V, I <sub>D</sub> =6.0A
V <sub>SD</sub>	Diode Forward Voltage ④	—	1.6	—	1.6	V	V <sub>GS</sub> = 0V, I <sub>S</sub> = 9.0A

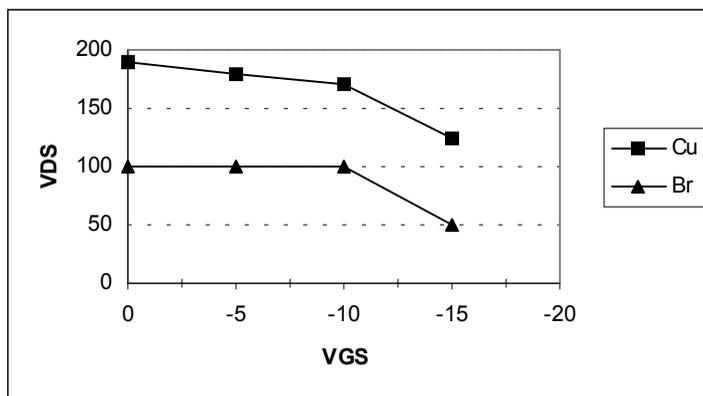
1. Part numbers IRHM7230

2. Part number IRHM3230, IRHM4230, IRHM8230

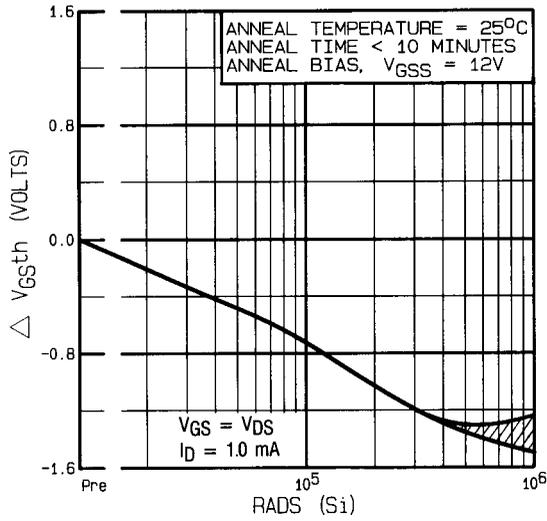
International Rectifier radiation hardened MOSFETs have been characterized in heavy ion environment for Single Event Effects (SEE). Single Event Effects characterization is illustrated in Fig. a and Table 2.

**Table 2. Single Event Effect Safe Operating Area**

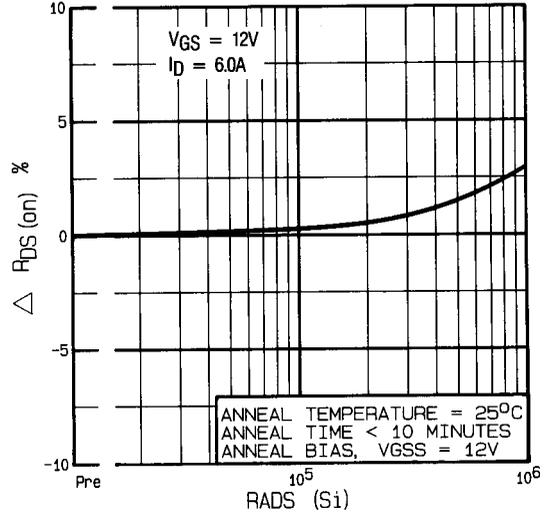
Ion	LET MeV/(mg/cm <sup>2</sup> )	Energy (MeV)	Range (μm)	V <sub>ds</sub> (V)				
				@V <sub>GS</sub> =0V	@V <sub>GS</sub> =-5V	@V <sub>GS</sub> =-10V	@V <sub>GS</sub> =-15V	@V <sub>GS</sub> =-20V
Cu	28	285	43	190	180	170	125	—
Br	36.8	305	39	100	100	100	50	—



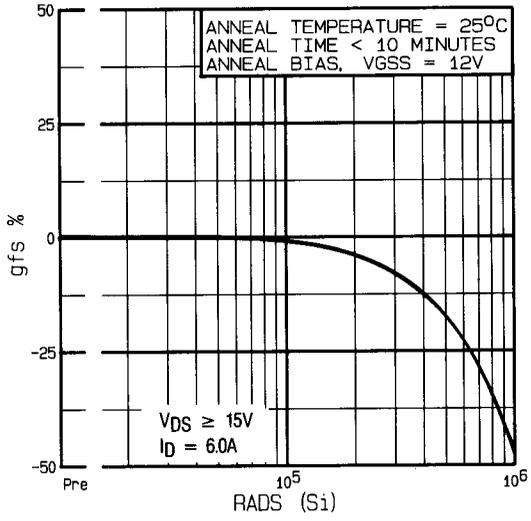
**Fig a. Single Event Effect, Safe Operating Area**



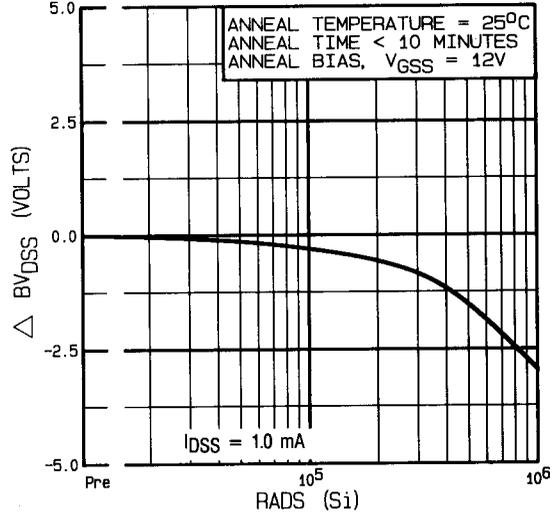
**Fig 1.** Typical Response of Gate Threshold Voltage Vs. Total Dose Exposure



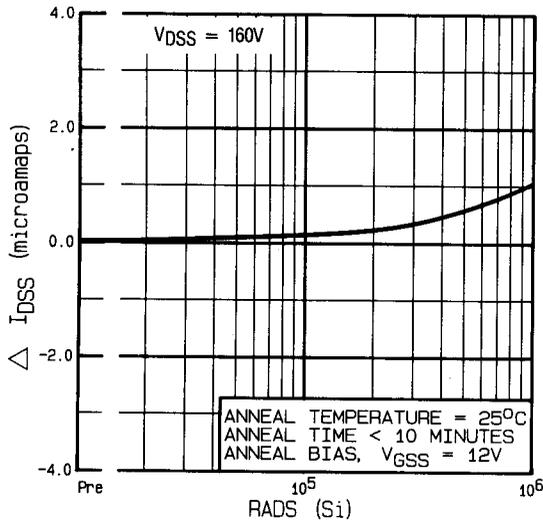
**Fig 2.** Typical Response of On-State Resistance Vs. Total Dose Exposure



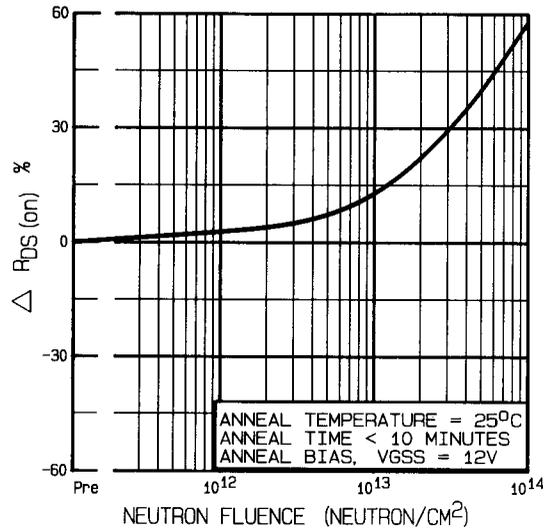
**Fig 3.** Typical Response of Transconductance Vs. Total Dose Exposure



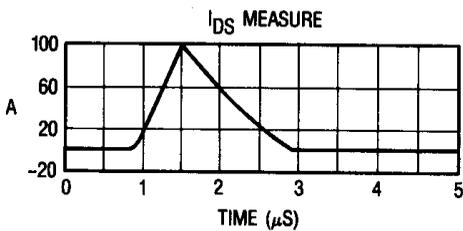
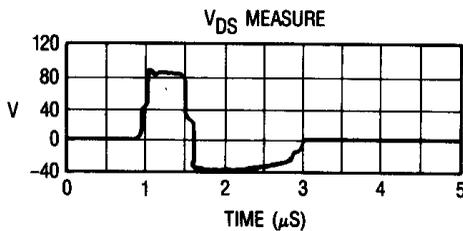
**Fig 4.** Typical Response of Drain to Source Breakdown Vs. Total Dose Exposure



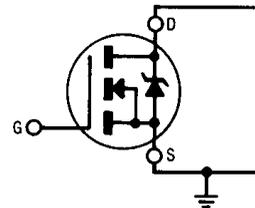
**Fig 5.** Typical Zero Gate Voltage Drain Current Vs. Total Dose Exposure



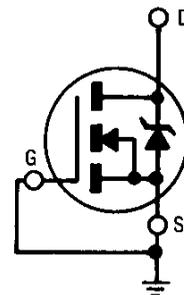
**Fig 6.** Typical On-State Resistance Vs. Neutron Fluence Level



**Fig 7.** Typical Transient Response of Rad Hard HEXFET During  $1 \times 10^{12}$  Rad (Si)/Sec Exposure



**Fig 8a.** Gate Stress of  $V_{GSS}$  Equals 12 Volts During Radiation



**Fig 8b.**  $V_{DSS}$  Stress Equals 80% of  $B_{VDSS}$  During Radiation

Note: Bias Conditions during radiation:  $V_{GS} = 12\text{ Vdc}$ ,  $V_{DS} = 0\text{ Vdc}$

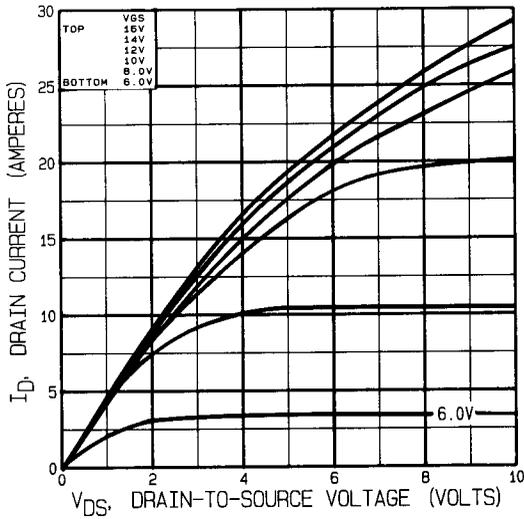


Fig 9. Typical Output Characteristics Pre-Irradiation

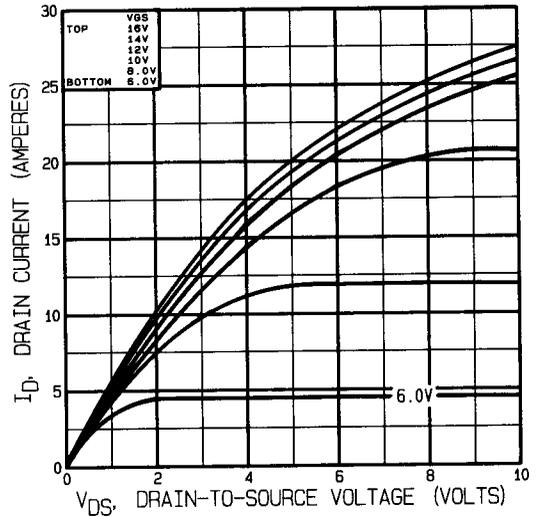


Fig 10. Typical Output Characteristics Post-Irradiation 100K Rads (Si)

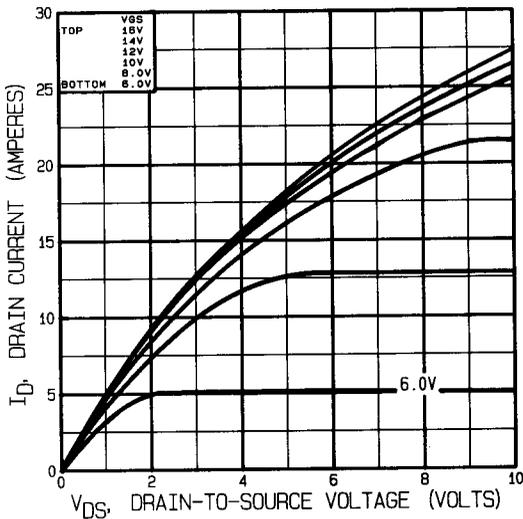


Fig 11. Typical Output Characteristics Post-Irradiation 300K Rads (Si)

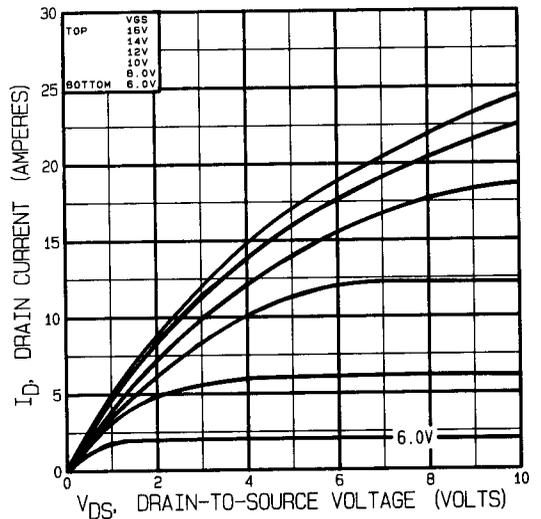
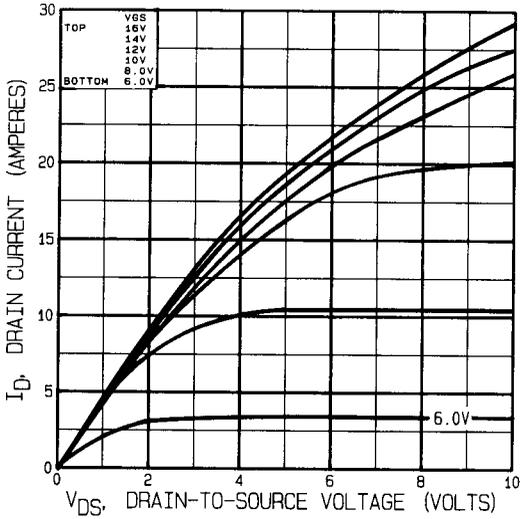


Fig 12. Typical Output Characteristics Post-Irradiation 1 Mega Rads (Si)

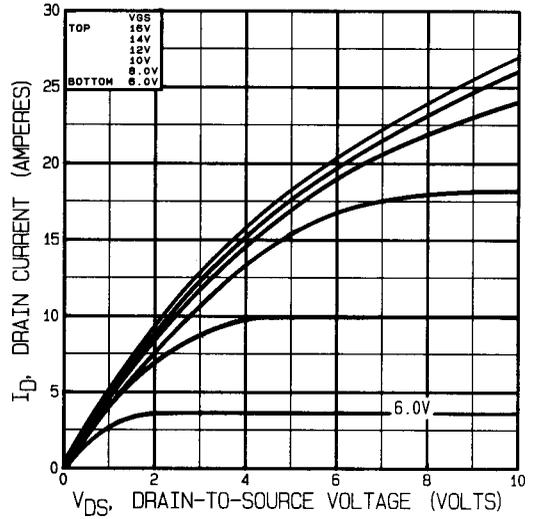
# Radiation Characteristics

IRHM7230

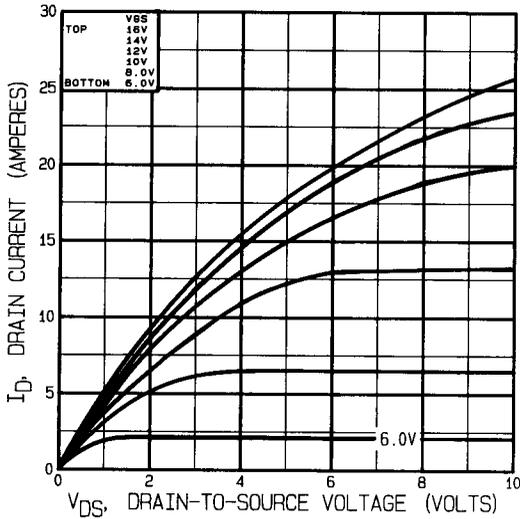
Note: Bias Conditions during radiation:  $V_{GS} = 0$  Vdc,  $V_{DS} = 160$  Vdc



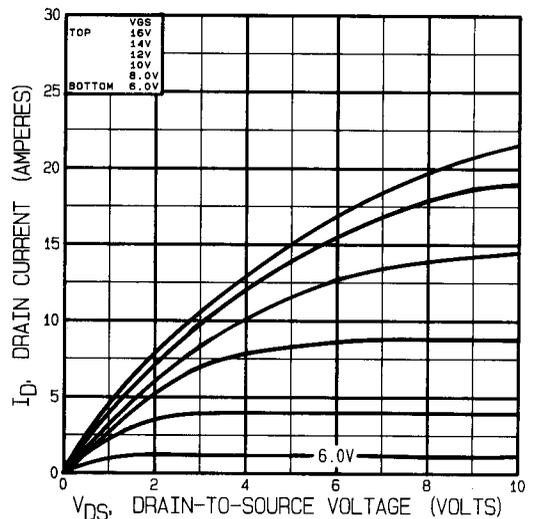
**Fig 13.** Typical Output Characteristics Pre-Irradiation



**Fig 14.** Typical Output Characteristics Post-Irradiation 100K Rads (Si)



**Fig 15.** Typical Output Characteristics Post-Irradiation 300K Rads (Si)



**Fig 16.** Typical Output Characteristics Post-Irradiation 1 Mega Rads (Si)

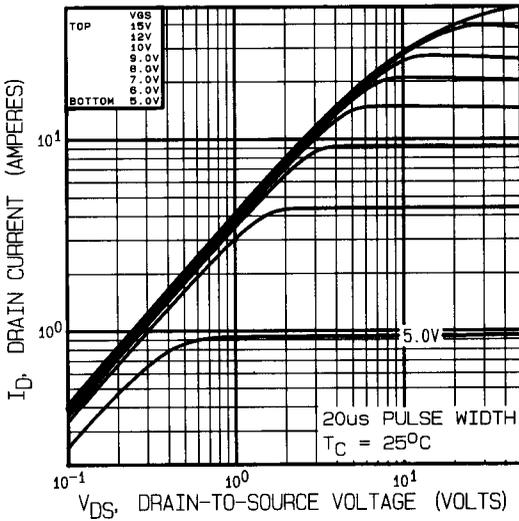


Fig 17. Typical Output Characteristics

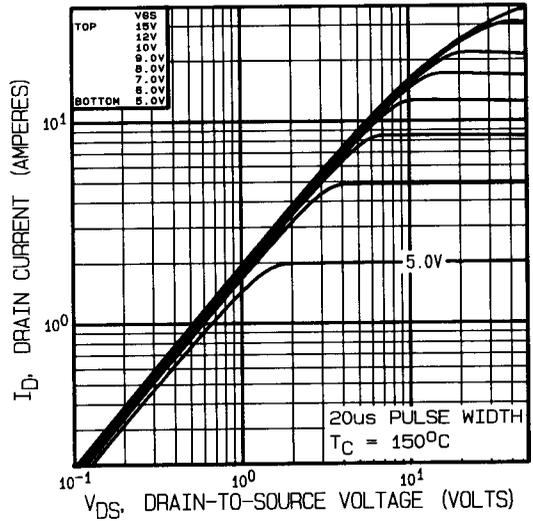


Fig 18. Typical Output Characteristics

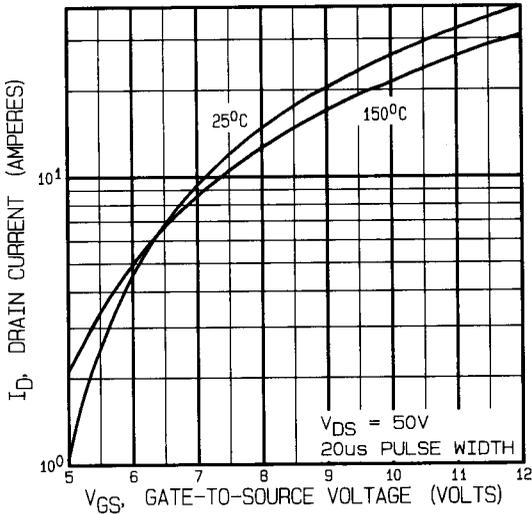


Fig 19. Typical Transfer Characteristics

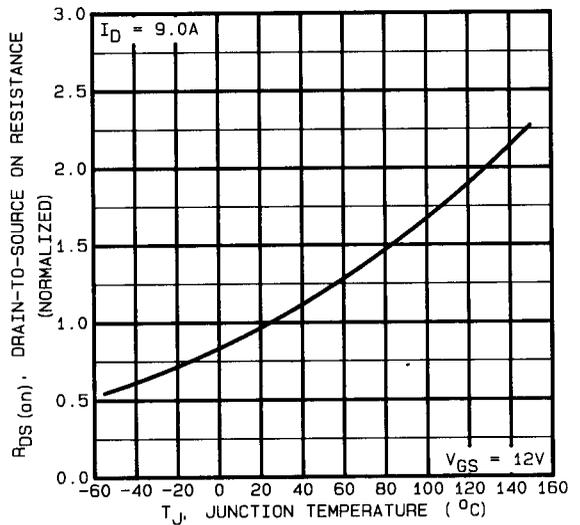


Fig 20. Normalized On-Resistance Vs. Temperature

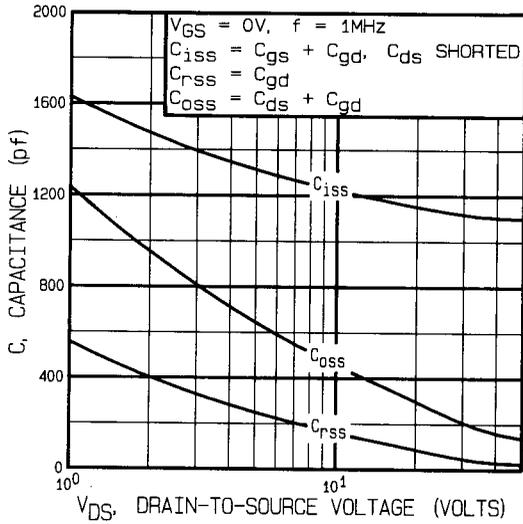


Fig 21. Typical Capacitance Vs. Drain-to-Source Voltage

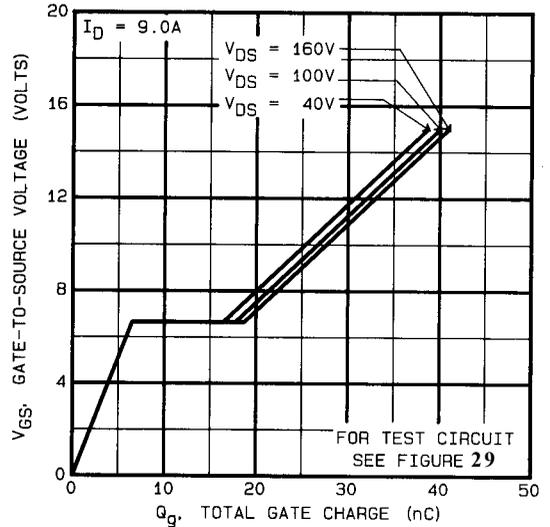


Fig 22. Typical Gate Charge Vs. Gate-to-Source Voltage

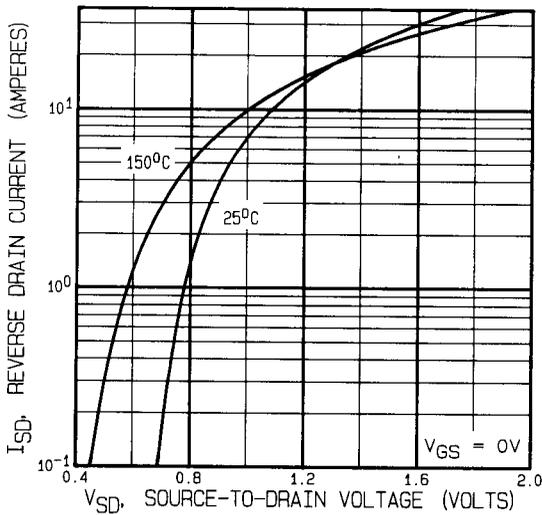


Fig 23. Typical Source-Drain Diode Forward Voltage

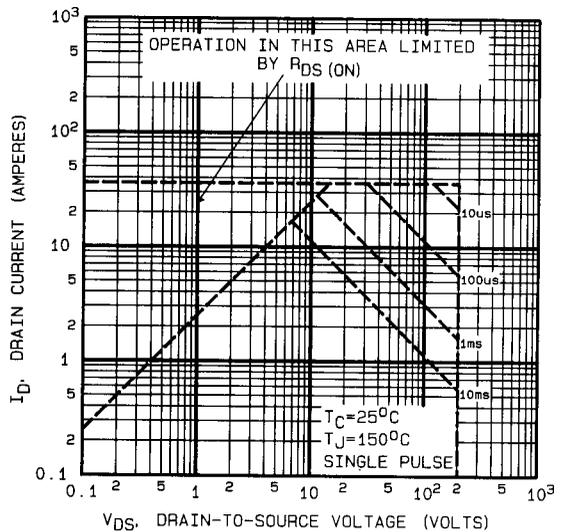


Fig 24. Maximum Safe Operating Area

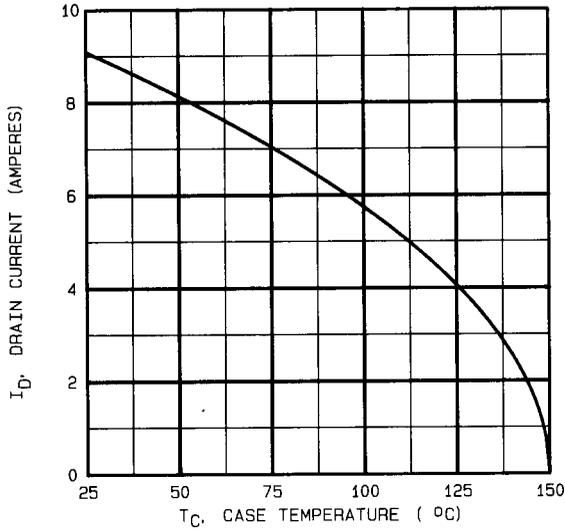


Fig 25. Maximum Drain Current Vs. Case Temperature

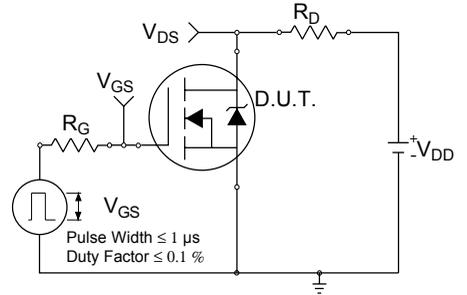


Fig 26a. Switching Time Test Circuit

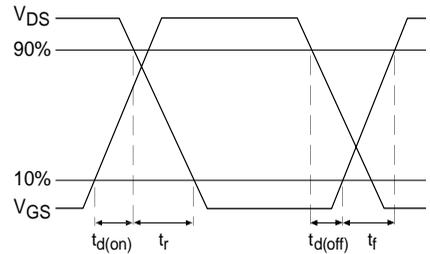


Fig 26b. Switching Time Waveforms

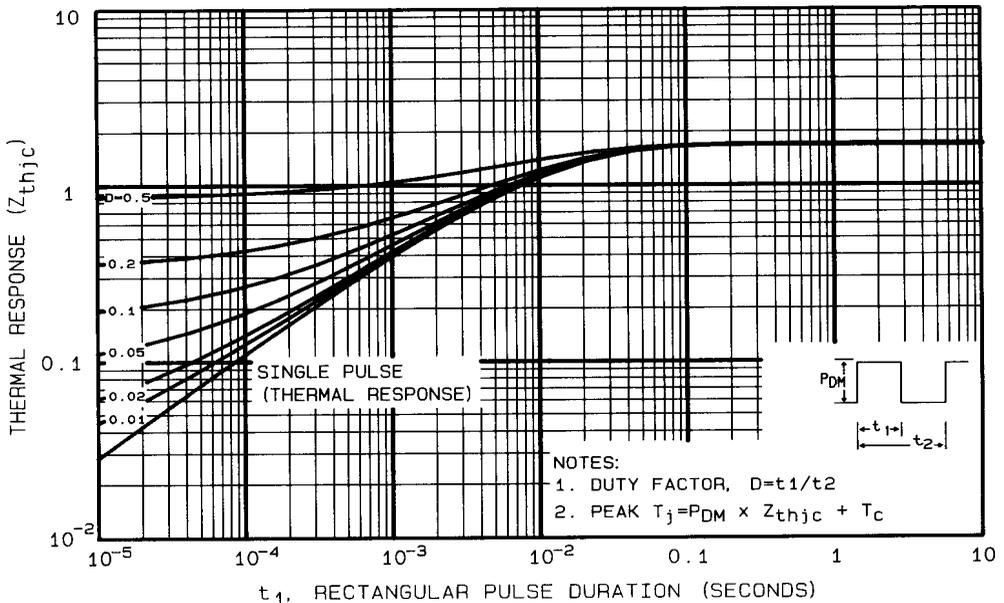


Fig 27. Maximum Effective Transient Thermal Impedance, Junction-to-Case

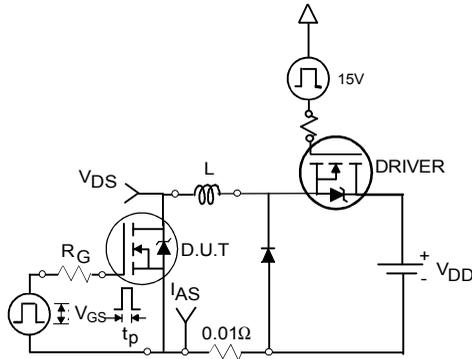


Fig 28a. Unclamped Inductive Test Circuit

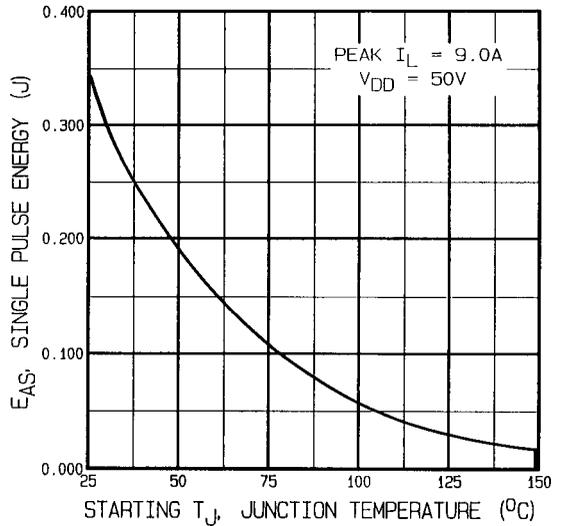


Fig 28c. Maximum Avalanche Energy Vs. Drain Current

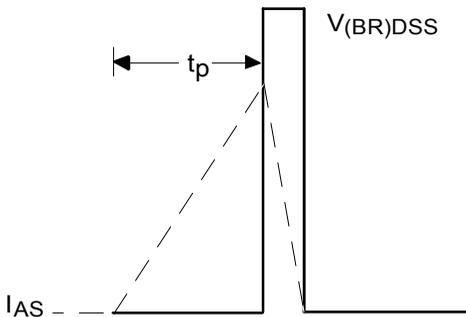


Fig 28b. Unclamped Inductive Waveforms

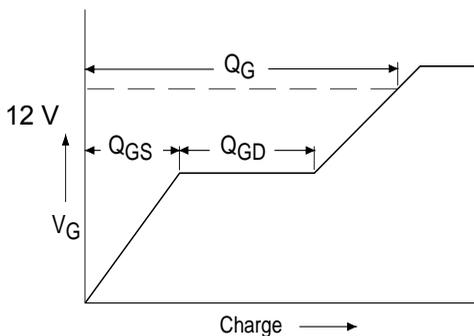


Fig 29a. Basic Gate Charge Waveform

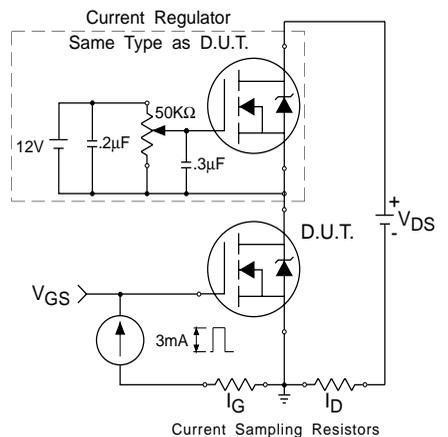
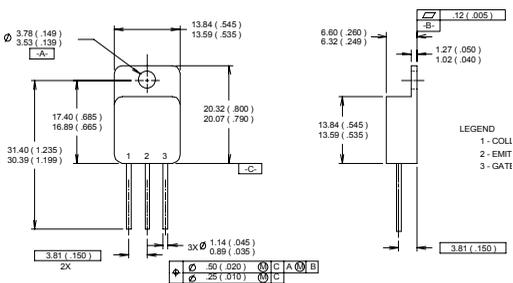


Fig 29b. Gate Charge Test Circuit

Foot Notes:

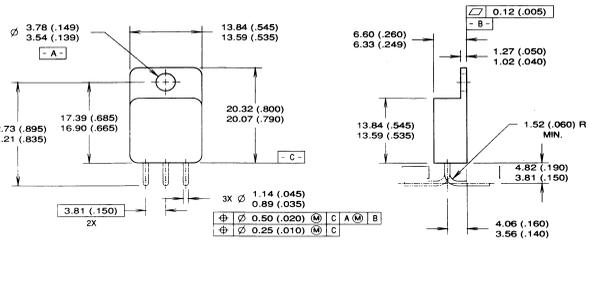
- ① Repetitive Rating; Pulse width limited by maximum junction temperature.
- ②  $V_{DD} = 25V$ , starting  $T_J = 25^{\circ}C$ ,  $L=8.15mH$   
Peak  $I_L = 9.0A$ ,  $V_{GS} = 12V$
- ③  $I_{SD} \leq 9.0A$ ,  $di/dt \leq 120A/\mu s$ ,  
 $V_{DD} \leq 200V$ ,  $T_J \leq 150^{\circ}C$
- ④ Pulse width  $\leq 300 \mu s$ ; Duty Cycle  $\leq 2\%$
- ⑤ **Total Dose Irradiation with  $V_{GS}$  Bias.**  
12 volt  $V_{GS}$  applied and  $V_{DS} = 0$  during irradiation per MIL-STD-750, method 1019, condition A.
- ⑥ **Total Dose Irradiation with  $V_{DS}$  Bias.**  
160 volt  $V_{DS}$  applied and  $V_{GS} = 0$  during irradiation per MIL-STD-750, method 1019, condition A.

Case Outline and Dimensions — TO-254AA



NOTES:

- 1. DIMENSIONING & TOLERANCING PER ANSI Y14.5M-1982.
- 2. DIMENSIONS ARE SHOWN IN MILLIMETERS [INCHES].
- 3. LEADFORM IS AVAILABLE IN EITHER ORIENTATION



LEGEND

- 1- DRAIN
- 2- SOURCE
- 3- GATE

CAUTION

**BERYLLIA WARNING PER MIL-PRF-19500**

Package containing beryllia shall not be ground, sandblasted, machined, or have other operations performed on them which will produce beryllia or beryllium dust. Furthermore, beryllium oxide packages shall not be placed in acids that will produce fumes containing beryllium.